

HIGH-PERFORMANCE-SENSORSYSTEME durch Verbindung von Siliziumtechnologie und keramischer Mehrlagentechnik

# HIPS | HIGH PERFORMANCE SENSORS

*Powered by SiCer - The best of both worlds*

## Demonstrators of the SiCer Technology

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# From technology to applications

Verbundprojekt 1:  
**TECHNOLOGIEPLATTFORM SiCer**

- **MATERIALTECHNOLOGIE**  
 (Keramik, Metalle, Benetzungssteuerung, Widerstände, Funktionalisierungen, Verkappung)
- **PROZESSTECHNOLOGIE**  
 (Silicium- und Keramikbearbeitung, Stapeln, Laminieren, Sintern, Post-Processing, AVT, Vereinzelung)
- **STRUKTURELEMENTE**  
 (Elektroden, Vias, Kanäle, Kavitäten, Membranen, Balken, Federn, Fenster, Heizer)

Verbundprojekt 2:  
**SiCer FLÜSSIGKEITSSSENSOREN**

Verbundprojekt 3:  
**SiCer GASSENSOREN**



Sicer-based technologies are used for various application scenarios/sensor applications.

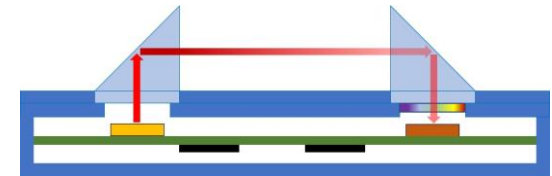
# Multi-Lambda-Sensor

- Application-oriented design through stacking / bonding / sintering of different materials
- Miniaturization

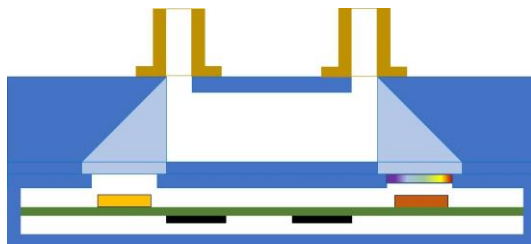
Principle of SiCer-Multi- $\lambda$ -Sensor



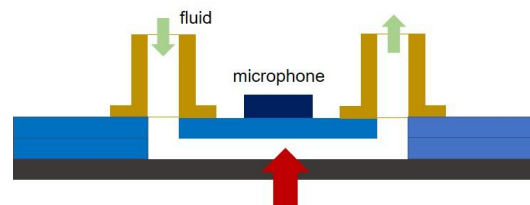
Transmission open water



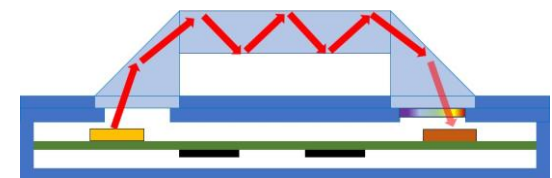
Transmission microfluidic



Photoacoustic

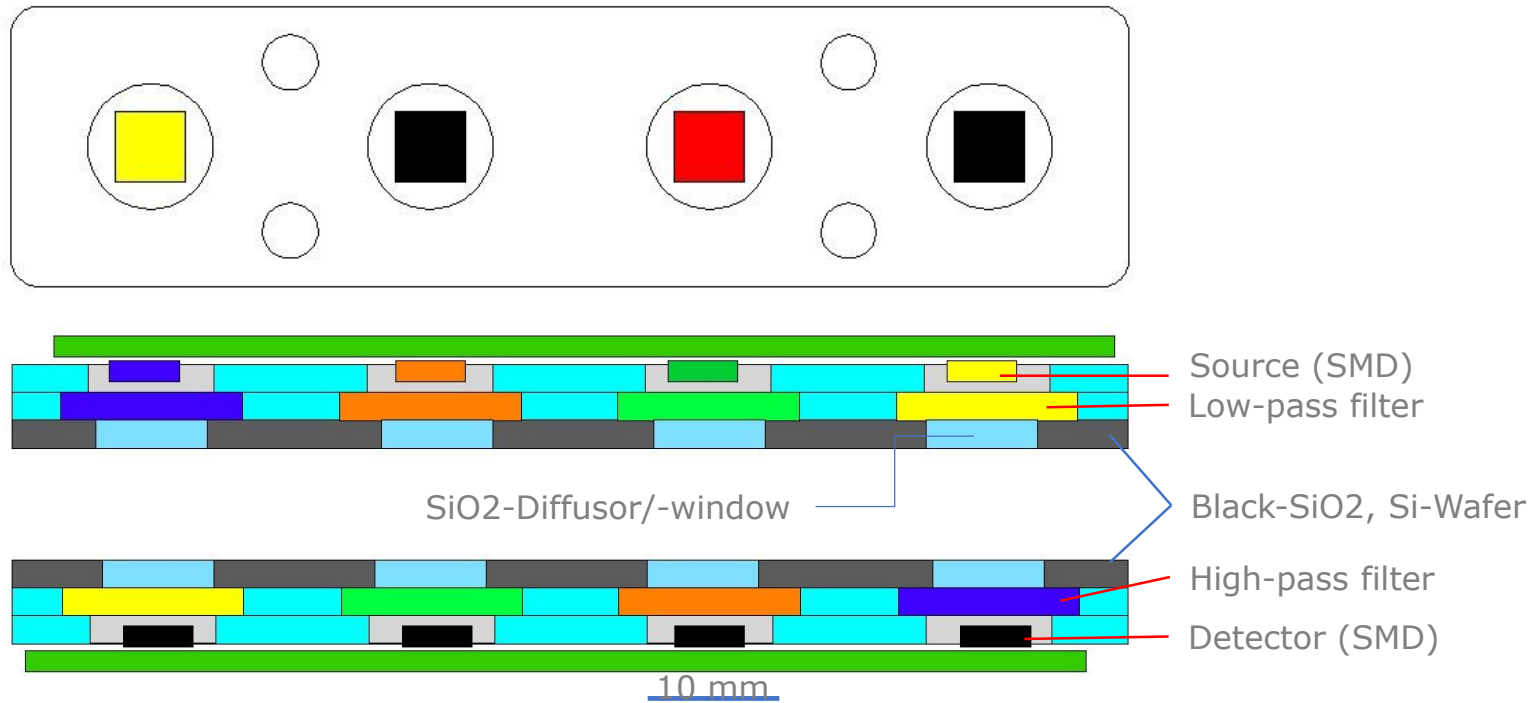


ATR Elektrolyte



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# Linear Array- water monitoring

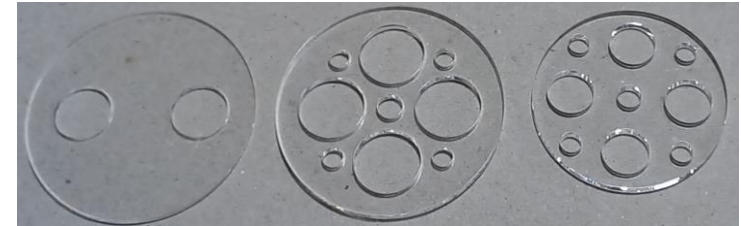
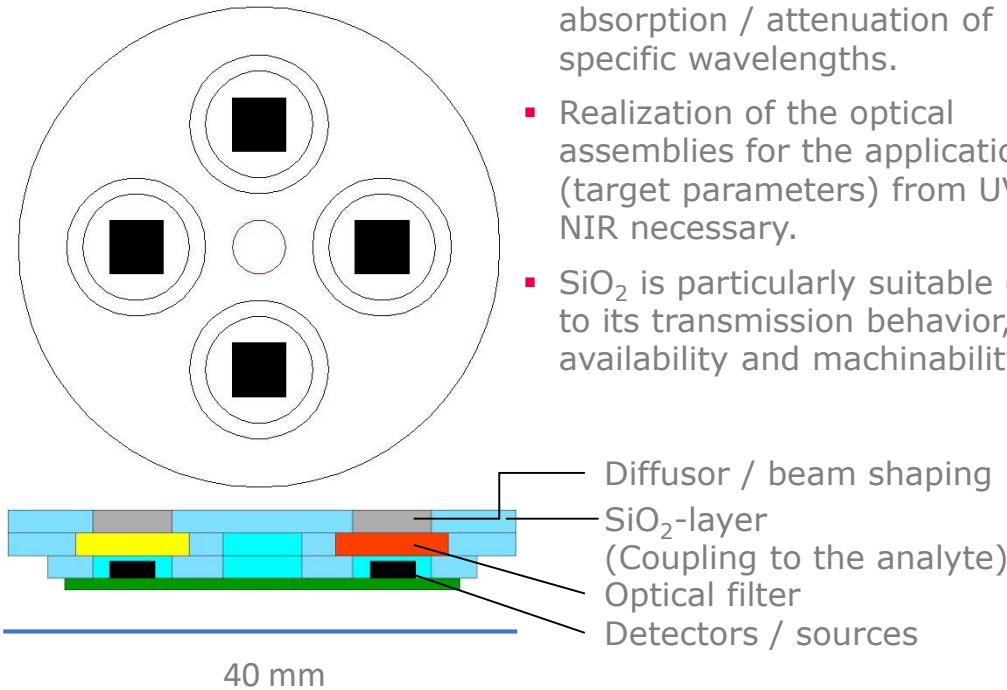


Sandwich design with discrete components

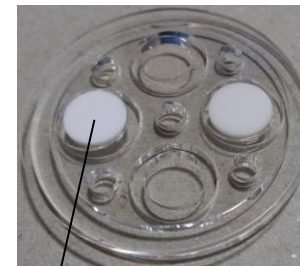
- transferable to SiCer (if available)
- miniaturization with LTCC (PCB)
- Goal: Testing of measurement techniques in situ

# Multi-Lambda-Sensor (Demonstrator)

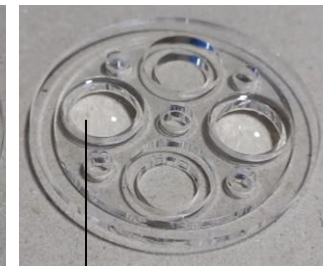
- Determination of target parameters in water by absorption / attenuation of specific wavelengths.
- Realization of the optical assemblies for the applications (target parameters) from UVC to NIR necessary.
- SiO<sub>2</sub> is particularly suitable due to its transmission behavior, availability and machinability.



SiO<sub>2</sub>-Layers



SiO<sub>2</sub>-Diffusors



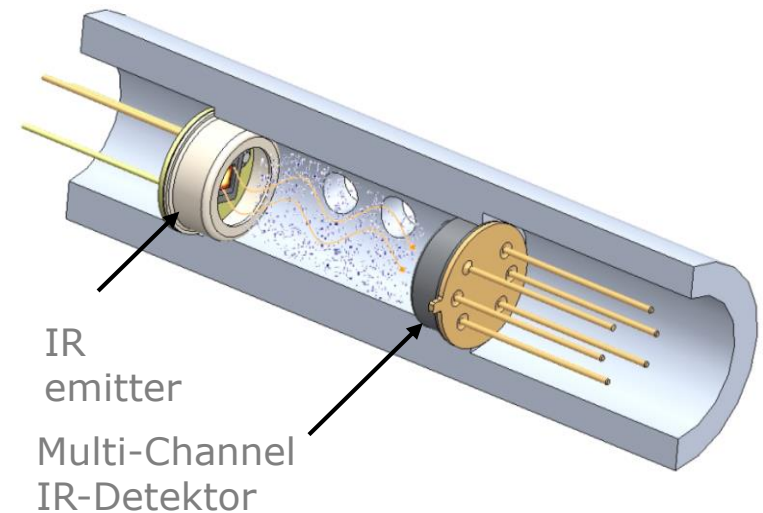
SiO<sub>2</sub>-Lens

SiO<sub>2</sub>-stacked layers

# IR emitters and Detectors

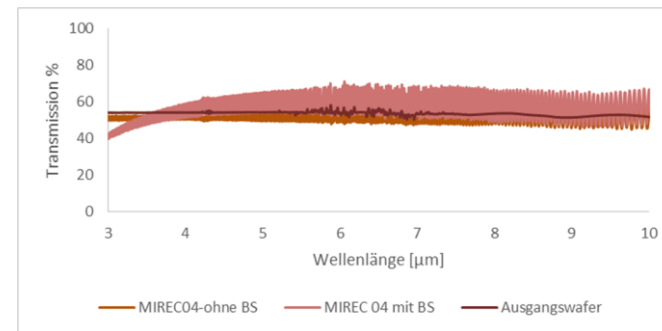
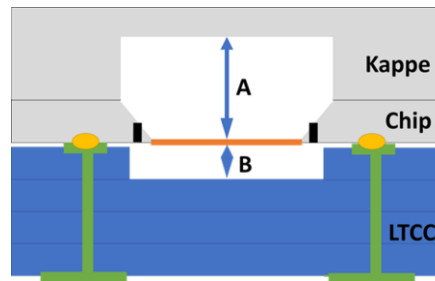
## Principle

- The measuring cell is filled with a gas mixture to be analyzed.
- IR radiation source and detector at opposite ends
- The detector includes a filter of the absorption wavelength of the gas to be detected.
- Absorption of IR radiation by the gas to be detected results in attenuation of IR radiation of that wavelength.
- The signal depends on the concentration of the gas.



# IR emitters and detectors

- Layout for IR emitter (heater) and IR detector as well as processing Si wafers and cap wafers for IR emitter and detector (with/without black Si)
- Reflection/transmission characterization



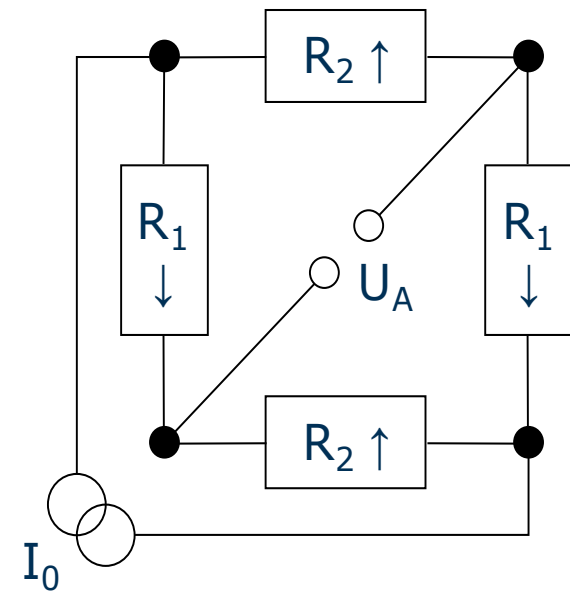
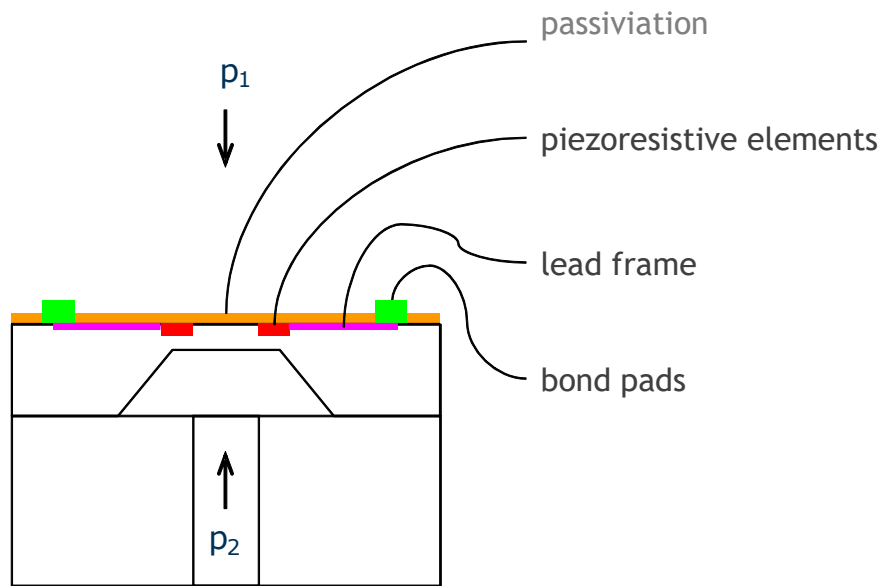
- Target: highest possible transmission in the range 3-5μm
- Transmission at about 50%
- from 3.5 μm transmission with Si needles approx. 10% higher than without Si needles (black silicon)
- similar transmission in the long wavelength range

Source: MHE

# Principle of pressure sensors

## Principle

- Implanted resistors in silicon -> Wheatstone measuring bridge
- The silicon membrane is deflected by the applied pressure  $U_A \sim p$
- Scalable manufacturing processes

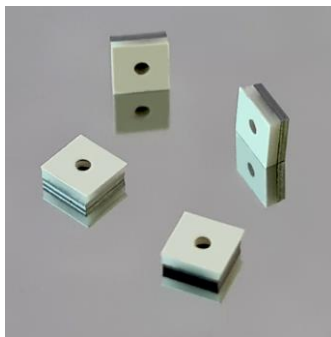


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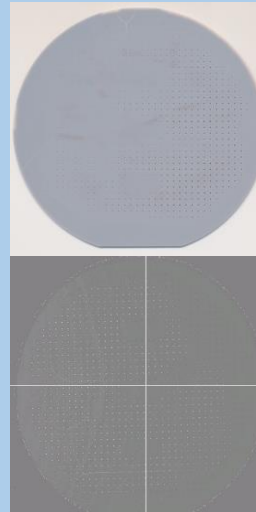


# Pressure sensor

- Layout for Si pressure sensor
- Processing of bare, dummy and pressure sensor wafers
- Technology transition and characterization from pressure sintering to pressure assisted sintering in
- pressure assisted sintering: Interface problems, no dislocation lines in Si.
- pressure sintering: Interface OK, cracks in the composite, dislocation lines in Si



## Pressure sintering

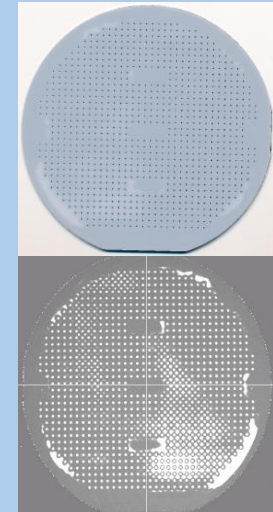


full bonded interface

Dislocation lines in Si,  
wedge error, partially  
squeezed channels

## pressure assisted sintering

Ceramic side



Bonding  
interface  
(SAM)

+ no dislocation lines in Si, no  
wedge error channel  
structure remains intact

- no fully bonded interface yet

Source: TUIL

# Temperature sensor



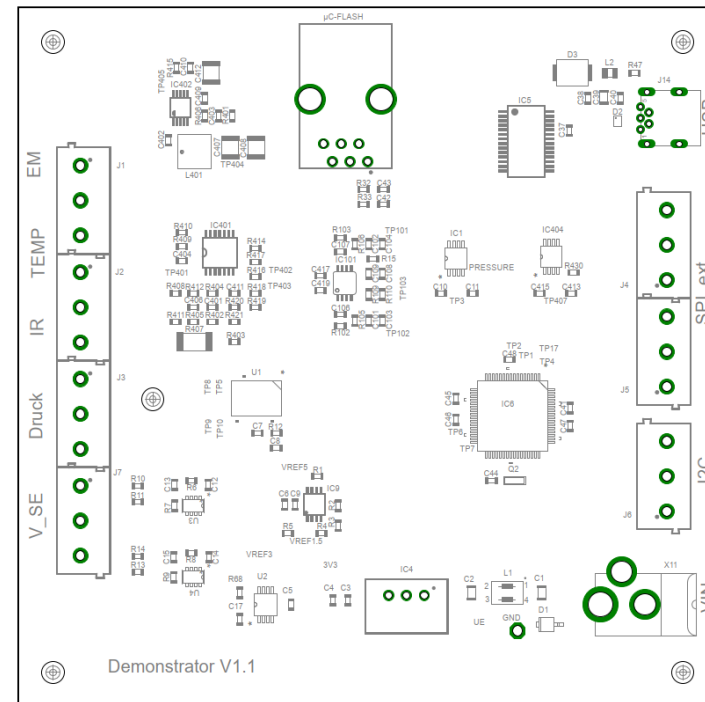
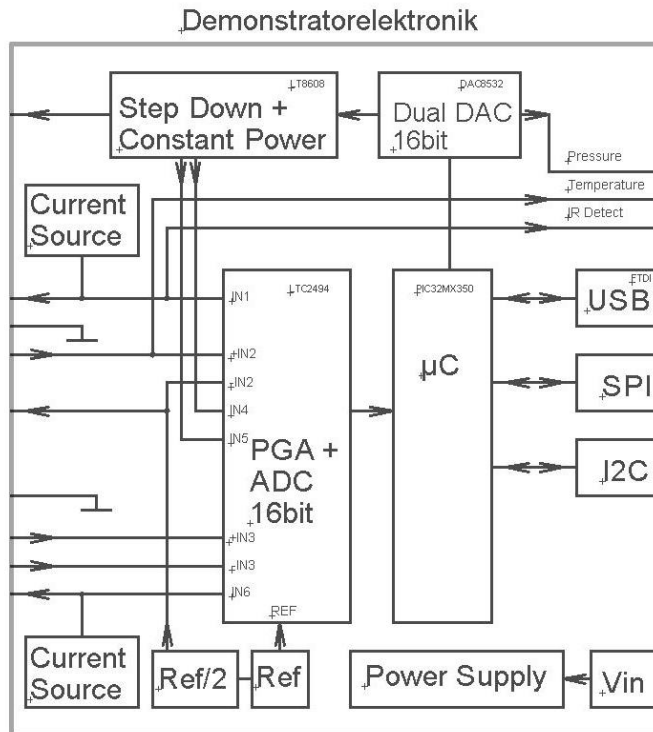
- Laboratory samples of the temperature sensor element successfully tested in the laboratory (including rapid temperature changes 30,000 cycles, RT/1100°C, a 60s, measurements characteristic curves, drifts, ...).
- Drift below target temperature deviation of  $\leq 1\%$  (from final value).
- Sensor electronics for conversion of the T-dependent resistance of the Pt200 into a frequency signal with compensation of contact and line resistances
- currently integration/miniaturization

Source: UST

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# Demonstrator

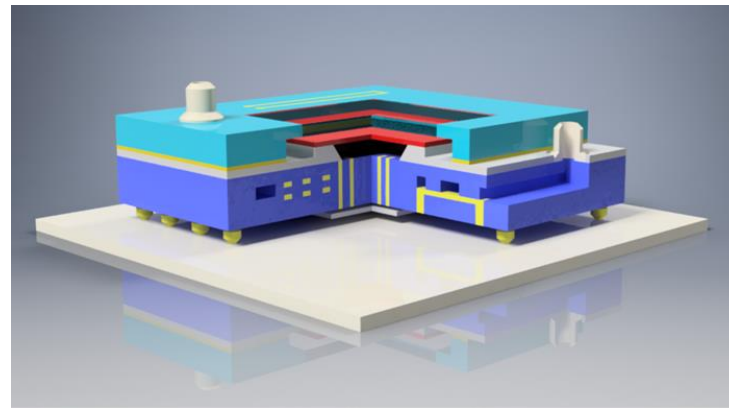
- Demonstrator -> system design
- Manufacturing and assembly of the electronic components



Source: MSE

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- The biggest challenge is the SiCer bonding process itself.
- Demonstrators for the various measured variables are in various stages of development.
- The work on the electronics and the system is less affected ->very satisfactory results here.



Source: TUIL



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Thank you!

